



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

August 4, 2026

IGI Report Number

LG823694134

Description

LABORATORY GROWN DIAMOND

Shape and Cutting Style

EMERALD CUT

Measurements

10.74 X 7.44 X 5.14 MM

GRADING RESULTS

Carat Weight

4.10 CARATS

Color Grade

E

Clarity Grade

VS 1

ADDITIONAL GRADING INFORMATION

Polish

EXCELLENT

Symmetry

EXCELLENT

Fluorescence

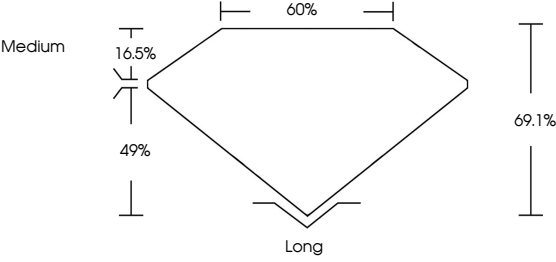
NONE

Inscription(s)

 LG823694134

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.
Type IIa

PROPORTIONS



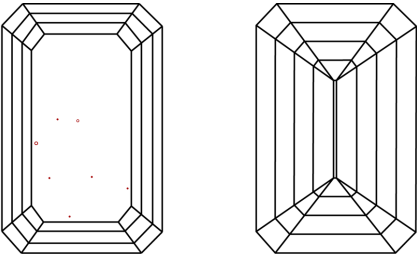
Medium

Long



Sample Image Used

CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

COLOR

D E F G H I J Faint Very Light Light

CLARITY

FL IF VVS 1-2 VS 1-2 SI 1-2 I 1-3

Flawless Internally Flawless Very Very Slightly Included Very Slightly Included Slightly Included Included

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IGI

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EMERALD CUT

4.10 CARATS

E

4.10 CARATS

E

VS 1

69.1%

60%

Medium

Long

EXCELLENT

EXCELLENT

NONE

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Type IIa

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